

[10191/4116]

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventor(s) : Franz LAERMER et al.
Serial No. : 10/524,610
Filed : August 11, 2005
For : LAYER SYSTEM HAVING A SILICON LAYER AND A
PASSIVATION LAYER, METHOD FOR CREATING A
PASSIVATION LAYER ON A SILICON LAYER AND ITS
USE
Examiner : Hoang Ho
Art Unit : 2818
Confirmation No. : 9981

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Commissioner for Patents
P.O. Box 1450
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AMENDMENT UNDER 37 C.F.R. § 1.116

SIR:

In response to the Final Office Action of August 2, 2010, for which the three-month response date expires on November 2, 2010, kindly amend the above-captioned application without prejudice as follows:

Amendments to the Claims are reflected in the listing of claims,
which begins on page 2 of this paper.

Remarks begin on page 4 of this paper.